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Spectral threshold extended photoresponse in asymmetric p-GaAs/AlGaAs heterostructure-based infrared detectors¹ DILIP CHAUHAN, A. G. UNIL PERERA, Department of Physics and Astronomy, Georgia State University, Atlanta, Georgia, 30303, USA, LIANHE LI, LI CHEN, EDMUND H LINFIELD, School of Electronic and Electrical Engineering, University of Leeds, Leeds LS2 9JT, United Kingdom — The spectral photoresponse threshold λ_t of a semiconductor photodetector is conventionally determined by $\lambda_t = hc/\Delta$, where Δ is the minimum energy gap of a material, or the interfacial energy gap of a heterostructure. In addition, the Δ at the material interface is the key parameter to determine the dark current and noise levels of the detector. Therefore, lowering the Δ to detect longer spectral region will have a trade-off with increased noise levels. Here, we present infrared detection in very-long-wavelength infrared (VLWIR) in a detector designed with a Δ for mid-infrared (MIR) region, in p-GaAs/AlGaAs heterostructures. Specifically, a detector designed with $\Delta = 0.40$ eV ($\lambda_t = 3.1$ μ m) showed an extended wavelength threshold up to 68 μ m, 45 μ m, and 60 μ m, under positive, zero, and negative biases respectively, at 5.3K. The dark current, however, was seen to correspond to $\Delta = 0.40$ eV, which was confirmed by a fitting obtained by using a 3D carrier drift model.

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